

Laborator nr. 4 FIZ :

Transistorul cu efect de câmp' (TEC)

- controlăm un curent I_D folosind o tensiune V_G
- dispozitiv comandat în tensiune

FET → „field-effect transistor”

TEC cu joncțiune (JFET)

TEC de tip MOS („metal-oxide-semiconductor”)

MOSFET

cu canal n
cu canal p

„depletion-mode”
(în regiim de sărăcire)

cu canal inițial

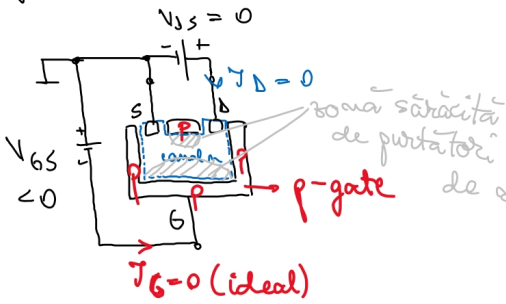
cu canal îndus

„enhancement-mode”
(în regiim de îmbogățire)

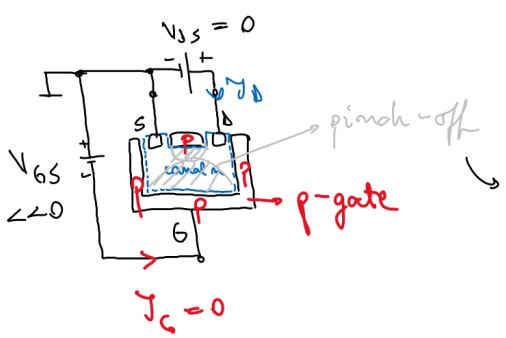
FET → limitează valoarea curentului de drenă I_D

JFET:

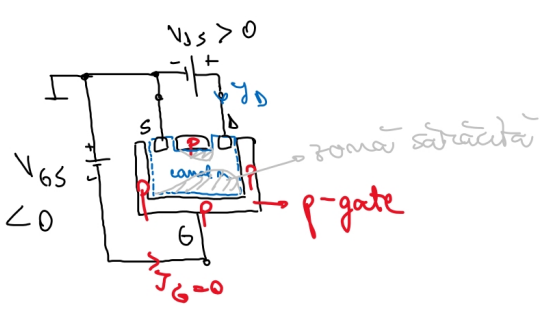
JFET cu canal n



D - drenă ("drain")
 S - sursă ("source")
 G - gate (grilă) de sarcină



pinch-off $\Rightarrow I_D = 0$
 pinch-off voltage V_T, V_P



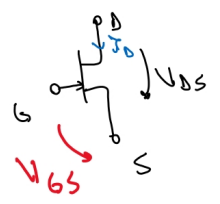
$$I_D = I_{DSS} \left(1 - \frac{V_{GS}}{V_T}\right)^2$$

I_{DSS}, V_T - tabelate (datasheet)

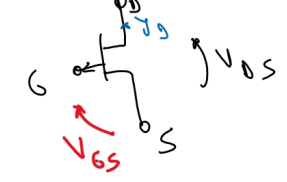
curent I_D de saturație

simbolurile JFET

cu canal n



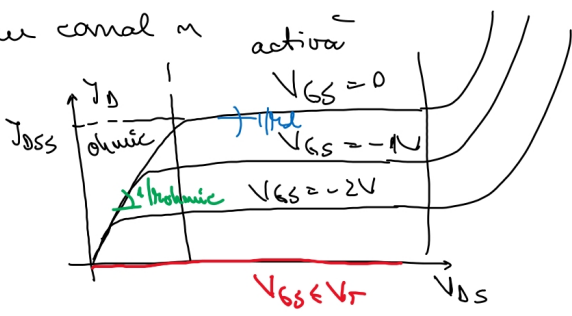
cu canal p



$$V_{GS} = 0 \Rightarrow I_D = I_{DSS}$$

$$V_{GS} = V_T \Rightarrow I_D = 0$$

Caracteristici JFET cu canal n



distorsione (străpungere)

parametrii de semnal mic ai FET

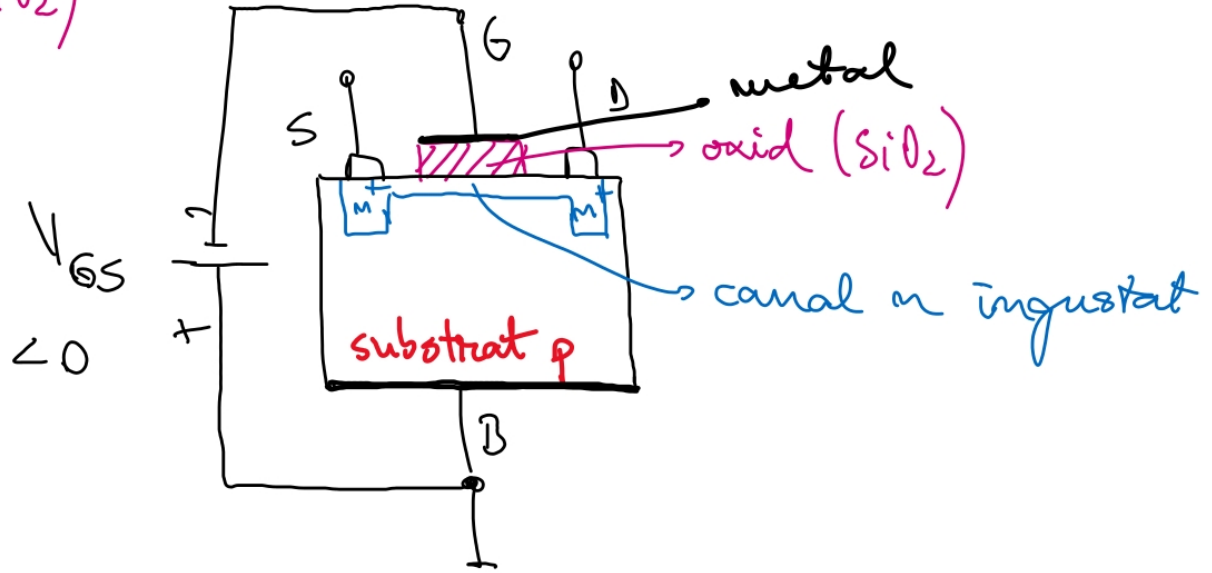
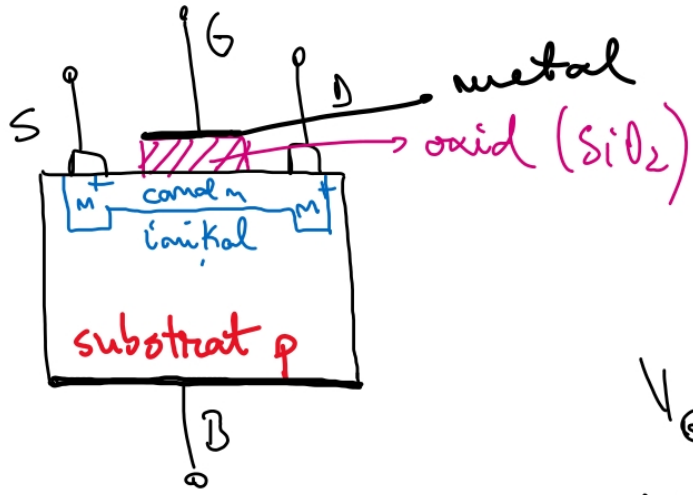
$$g_m = \left. \frac{\partial I_D}{\partial V_{GS}} \right|_{V_{DS} = \text{ct.}}$$

$$r_{d1}, r_{ohmic} = \left. \frac{\partial V_{DS}}{\partial I_D} \right|_{V_{GS} = \text{ct.}}$$

MOSFET cu canal inițial (mai rar)

MOSFET cu canal - $f.$ mică (muoni)

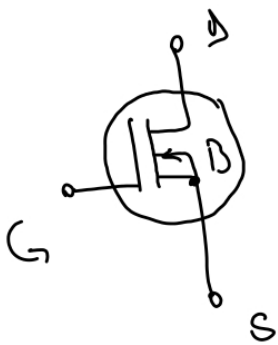
Z_{in} - $f.$ mare



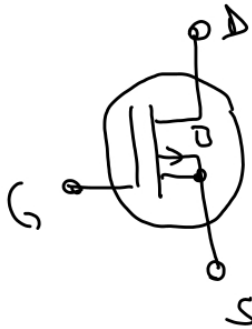
normally ON

caract. MOSFET cu canal inițial \equiv JFET.

simboluri MOSFET cu canal inițial



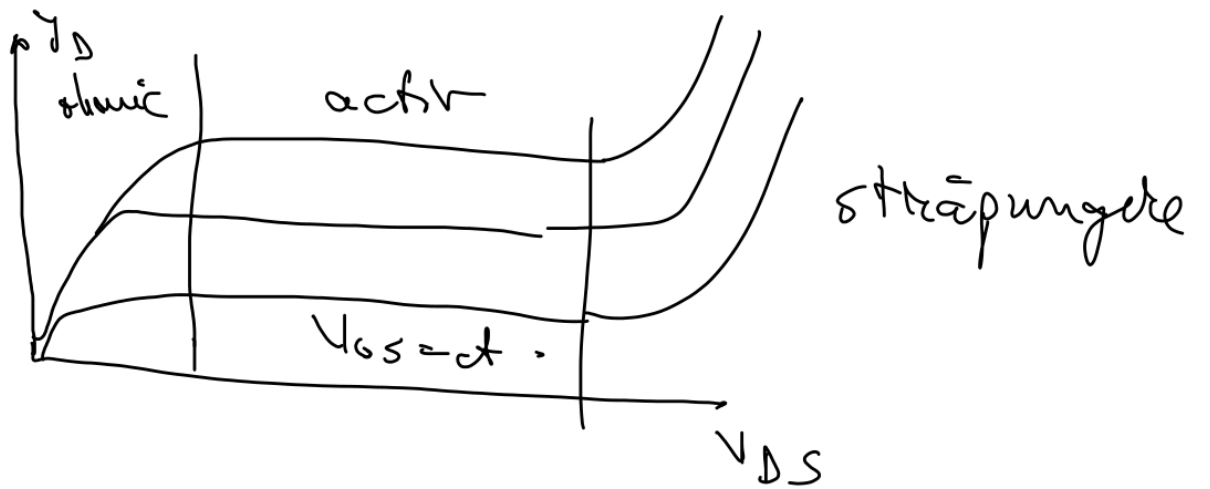
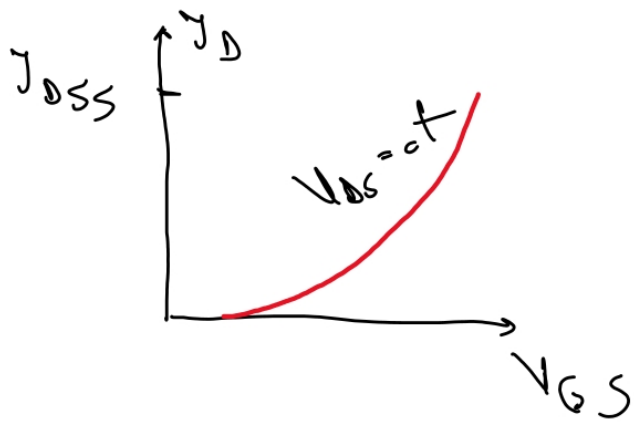
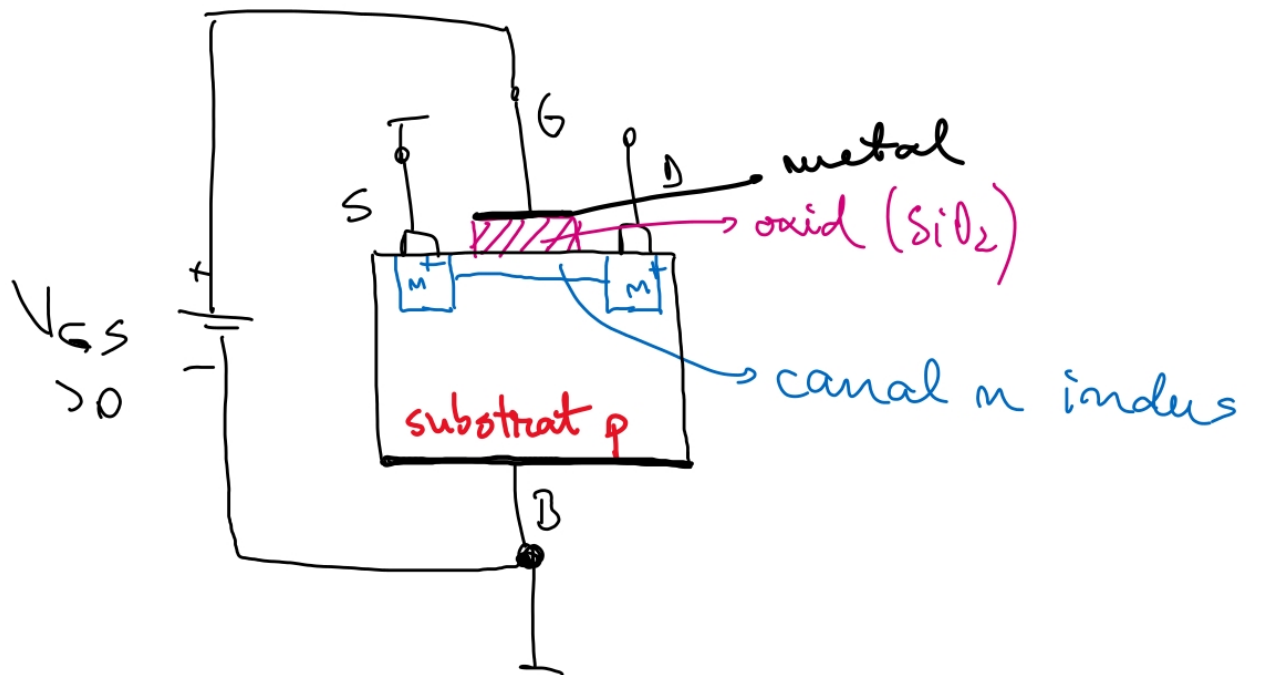
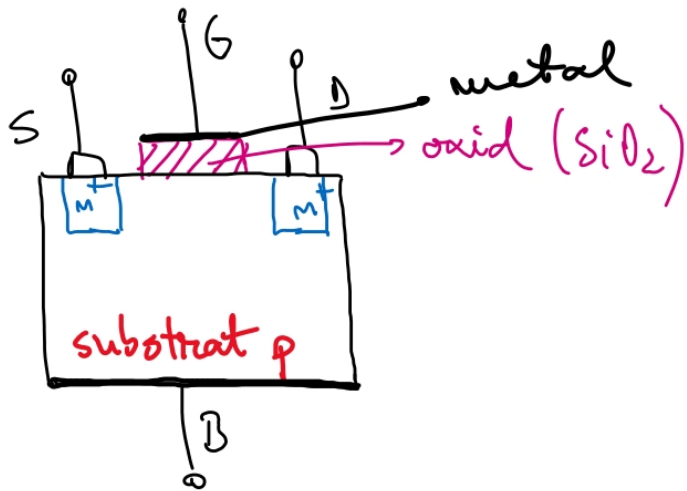
cu canal
n



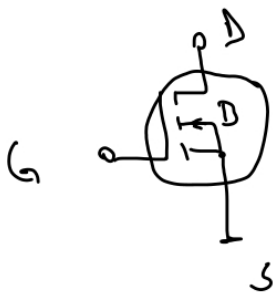
cu canal
p

MOSFET in canal indus:

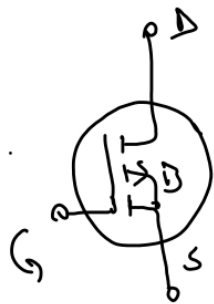
normally OFF



Symbolen



in canal
n



in canal
p

V_{GS} (V)	$V_{DS} = 5V$ I_D (mA)	$V_{DS} = 10V$ I_D (mA)
0	11.958	11.994
-0.1	11.555	11.59
;	;	;
-3.5	0	0

